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(N.E.)

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

filed 3-16-00
L. Spruill

In re Application of:

Gurtej S. Sandhu

Serial No.: 09/023,146

Filed: February 12, 1998

For: TUNGSTEN SILICIDE (WSIx)
DEPOSITION PROCESS FOR
SEMICONDUCTOR MANUFACTURE

Examiner: T. Dang

Group Art Unit: 2823

Attorney Docket No.: 3369US
(91-365-RE)

Box AF
Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

The following amendments and remarks are filed in response to the Examiner's remarks in the Final Office Action mailed December 28, 1999, the three-month shortened statutory period for response to which expires on March 28, 2000. This response is submitted on or before two months from the mailing date of the Final Office Action.

CERTIFICATE OF MAILING

I hereby certify that this correspondence along with any attachments referred to or identified as being attached or enclosed is being deposited with the United States Postal Service as First Class Mail (under 37 C.F.R. § 1.8(a)) on the date of deposit shown below with sufficient postage and in an envelope addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.

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Devin R. Jensen
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